

AMENDMENTS TO THE CLAIMS:

This listing of claims will replace all prior versions, and listings, of claims in the application:

LISTING OF CLAIMS:

1. (Original) A photosensitive resin composition containing a high molecular compound having at least a) a fluoro aliphatic group, and b) a group represented by formula LP (wherein L represents a divalent organic group connected to the skeleton of the high molecular compound, and P represents an aromatic group having a carboxyl group at the ortho-position).
2. (Canceled)
3. (Original) A photosensitive lithographic printing plate comprising a support having coated thereon a photosensitive layer containing the following components (a), (b) and (c),
 - (a) an o-naphthoquinonediazide compound,
 - (b) a resin soluble in an alkaline aqueous solution, and
 - (c) a polymer having a (meth)acrylate monomer having two or three perfluoroalkyl groups having from 3 to 20 carbon atoms in the molecule as a polymer component.

4. (Original) The photosensitive lithographic printing plate as claimed in claim 3,
wherein the polymer (c) is a copolymer of the a (meth)acrylate monomer having two or
three perfluoroalkyl groups having from 3 to 20 carbon atoms in the molecule and a
(meth)acrylate monomer having an OH group.

5.-6. (Canceled)